

***In-situ* synthesis of hierarchical MoSe₂-CoSe₂ nanotubes as efficient electrocatalyst for hydrogen evolution reaction in both acidic and alkaline medium**

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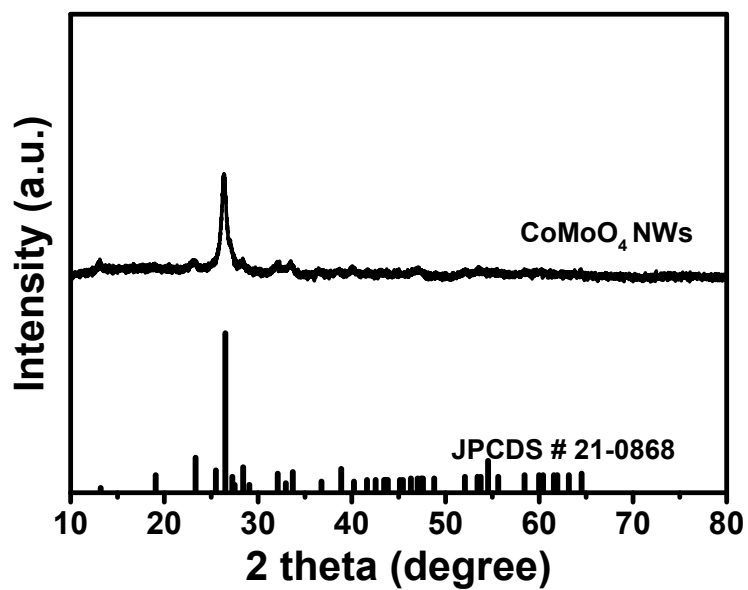


Fig. S1 XRD pattern of CoMoO₄ NWs

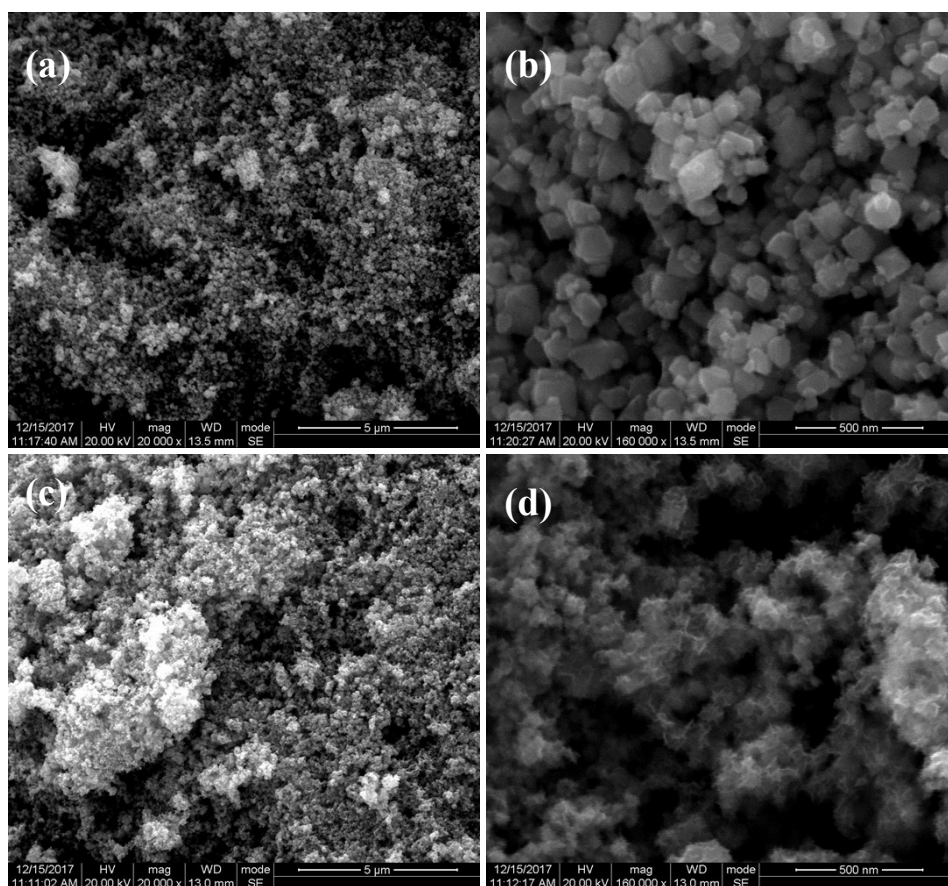


Fig. S2 (a-b) SEM images of CoSe₂ particles. (c-d) SEM images of MoSe₂ nanoflowers.

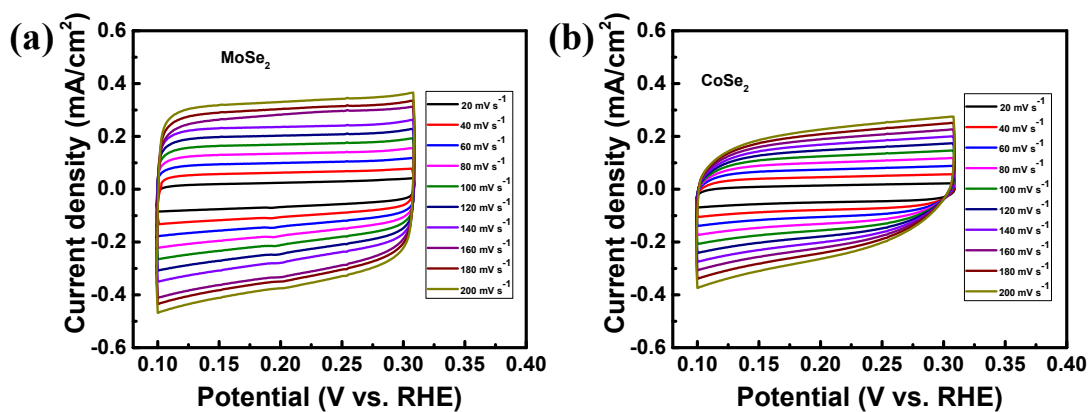


Fig. S3 Voltammograms of MoSe₂ and CoSe₂ recorded at the scan rates of 20–200 mV s⁻¹ in the region of 0.1–0.3 V vs. RHE.

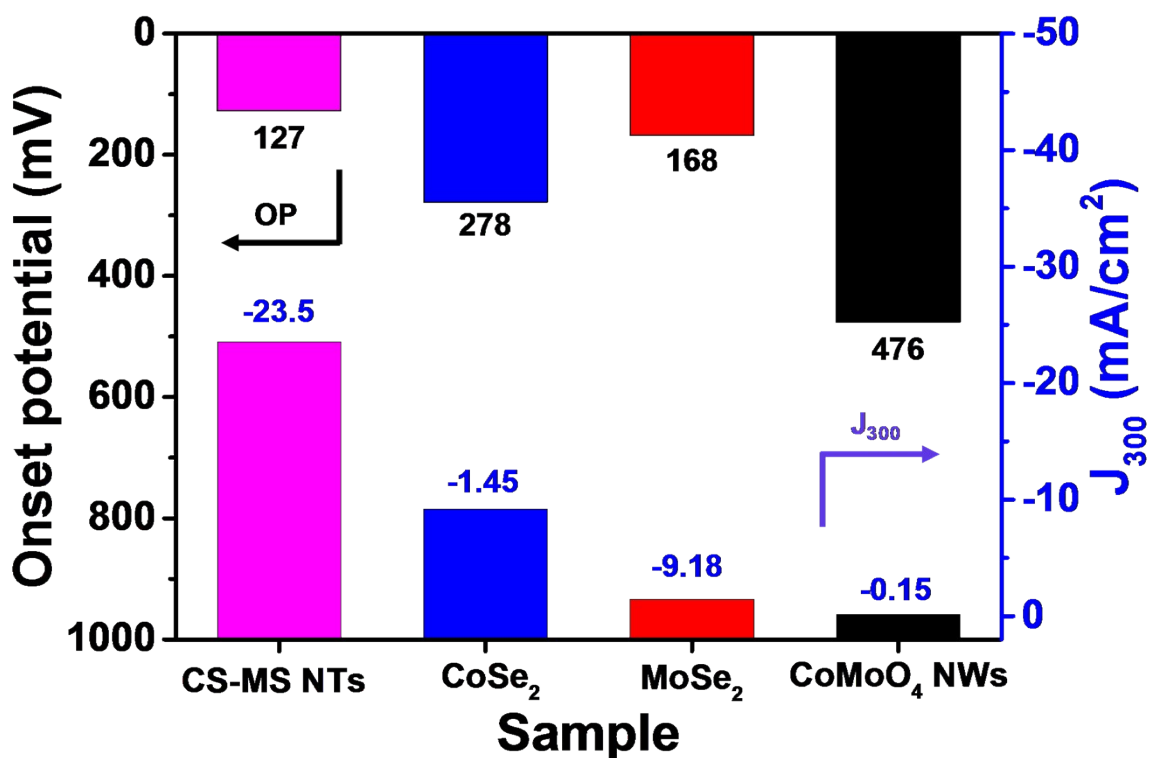


Fig. S4 Onset potential (op) and J₃₀₀ values of CoMoO₄ NWs, MoSe₂, CoSe₂ and MS-CS NTs in 1 M KOH.

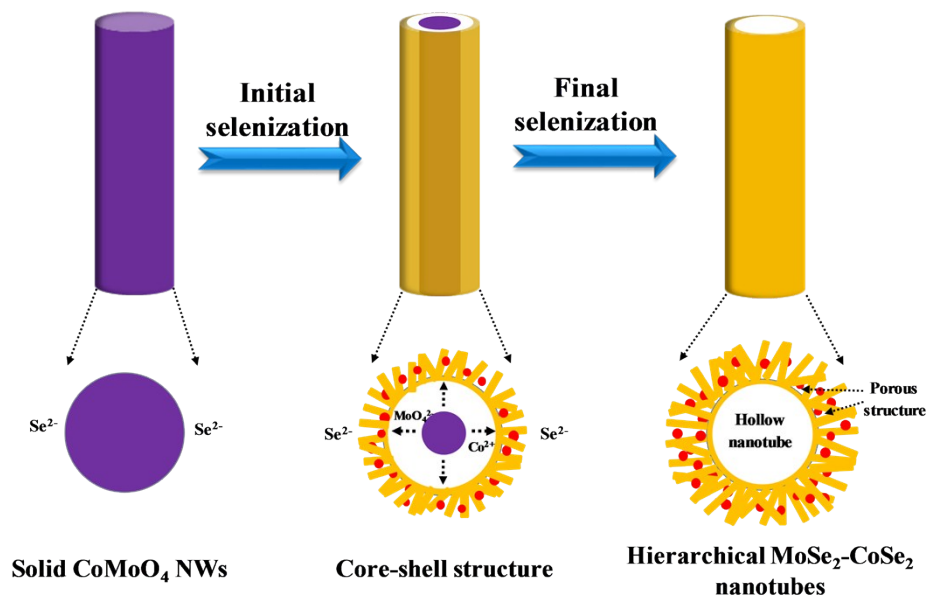


Fig. S5 Schematic illustration for the formation process and conversion mechanism of hierarchical MS-CS NTs.

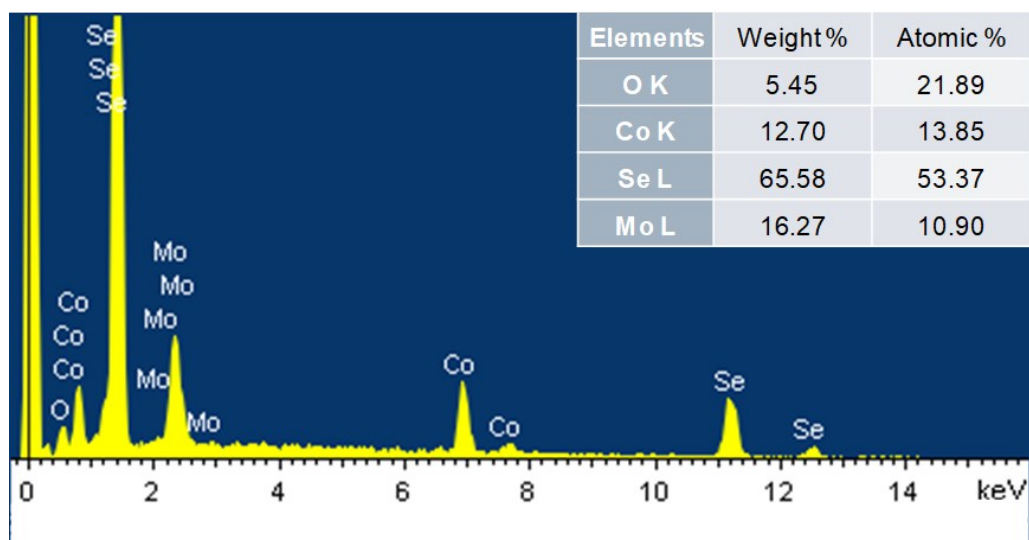


Fig. S6 EDS spectrum of the hierarchical MS-CS NTs.

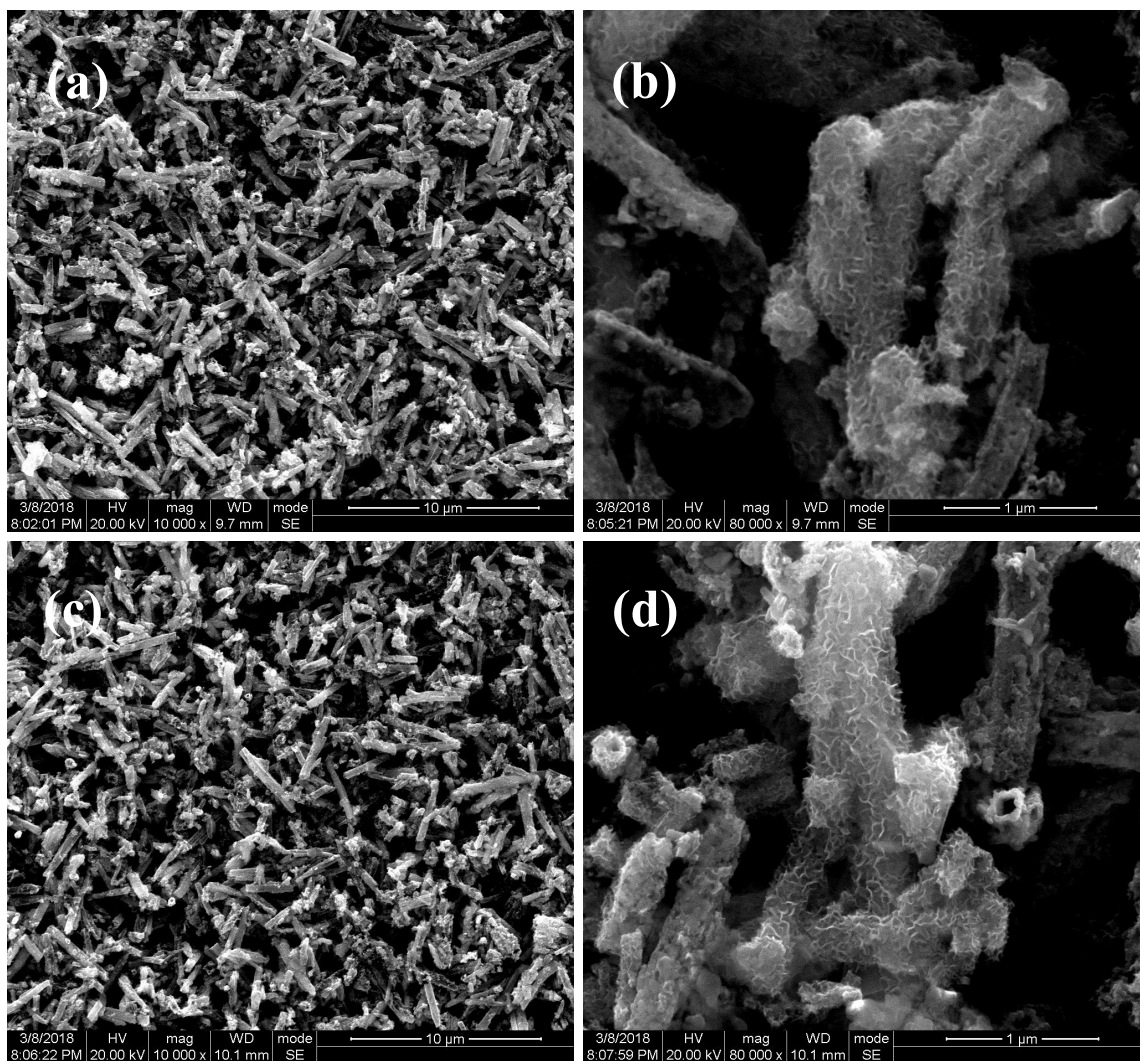


Fig. S7 (a-b) SEM images of MS-CS NTs after 1500 CV cycles in 0.5 M H₂SO₄. (c-d) SEM images of MS-CS NTs after 1500 CV cycles in 1 M KOH.

Table. S1 Summary of electrochemical performance of some advanced catalysts in previous works and our work.

Samples	Loading (mg/cm ²)	Onset overpotential (mV vs RHE)		J ₃₀₀ (mA/cm ²) @ 300 mV vs RHE		Tafel slope (mVdec ⁻¹)		References
		H ₂ SO ₄	KOH	H ₂ SO ₄	KOH	H ₂ SO ₄	KOH	
MS-CS NTs	0.57	148	127	-84.6	-23.5	45	89	This work
CoSe ₂ NPs	0.57	192	278	-40.1	-1.45	56	120	This work
MoSe ₂ NFs	0.57	169	168	-18.8	-9.8	83	104	This work
Mo _{1-x} W _x Se ₂	1	~150	~150	—	—	73	101	1
CoSe ₂ -SnSe ₂	0.57	>200	—	<10	—	74.5	—	2
CoS/MoS ₂	—	—	~130	—	~45	—	106	3
o-CoSe ₂	0.28	—	~120	—	~15	—	120	4
c-CoSe ₂	0.28	—	~100	—	~25	—	85	4
RGO/WSe ₂	0.57	~150	—	38.4	—	57.6	—	5
MoSe ₂ /CB	0.48	~150	—	~44	—	62	—	6
3D MoSe ₂	—	~200	—	~7	—	49.6	—	7
MoSe ₂ /Cu ₃ Se ₂	—	100	—	—	—	46	—	8
MoSe ₂ /CoMoSe	—	~150	—	~12	—	95.2	—	9
ZnSe/MoSe ₂	0.256	68	—	~52	—	73	—	10

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